Atty docket no: 52309-P004US Client ref: ARB/P1846US00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Ward, Luke

Application no: 10/516,448

PCT filed: May 30, 2003

Title: Application of a coating forming material onto at least one substrate

Examiner: Burkhart, Elizabeth A

Art unit: 1715

Confirmation no: 4683

DECLARATION UNDER 37 C.F.R.

1.132

DECLARATION OF PROFESSOR JAS PAL SINGH BADYAL

- I, Professor Jas Pal Singh Badyal, am a Full Professor of Chemistry at Durham University, England. My curriculum vitae, showing my qualifications and relevant technical experience, is annexed to this declaration as Annex I.
- 2. I have read the above-referenced patent application ("the present application") and its currently pending claims. I have also read the Office Action dated October 7, 2010, and both WO-02/28548 (Goodwin et al) and WO-98/58117 (Badyal et al), which are cited in that Office Action. I was the primary named inventor on both the Goodwin et al and the Badyal et al patent applications.
- 3. If have been asked to comment on the technology described in Goodwin et al and Badyal et al; on the way in which a person of ordinary skill in the art would interpret the two documents; and on the likelihood of that person combining the teachings of the two documents. I believe that I am competent to do this, given that: (i) I was the primary named inventor on both documents; (ii) I was the only named inventor on either document who had any prior expertise of either "pulsed gas-phase" plasma deposition or plasma deposition using atomised liquid droplets at

atmospheric pressure; (iii) all of the plasma deposition work described in both Goodwin et al and Badyal et al was carried out under my direct supervision in my research laboratory at Durham University by PhD students Luke Ward and Stephen Coulson respectively; and (iv) studies relating to the pulsed gas-phase technology of Badyal et al had been ongoing in my laboratory from 1992 to 1995, and studies relating to the Goodwin et al system, using atomised liquid droplets at atmospheric pressure, had been ongoing in my laboratory between 1995 and 1998.

- 4. Goodwin et al relates to a liquid-phase coating system in which the coating material is introduced in the form of atomised liquid droplets, at atmospheric pressure. Thus in this system, the coating material is not in gaseous form even though the surrounding exciting medium may be. Badyal et al, in contrast, relates to an entirely gas-phase deposition system carried out at reduced pressures. I believe that at the priority date of the present application (June 1, 2002), a person of ordinary skill in the art would have been discouraged from combining the two types of technology.
- 5. Gas-phase and liquid-phase plasma deposition systems are not analogous. This means that the skilled person would not have expected it to be straightforward to combine the teachings of Goodwin et al and Badyal et al. This is consistent with the fact that Goodwin et al, in proposing the use of atomisation in a plasma deposition system, made no mention of the possibility of pulsing the exciting medium. The document discussed earlier plasma deposition processes only from the point of view of their disadvantages (the requirement for reduced pressure, and the resultant expense see paragraph [0003]; the inability to work directly with liquid or solid coating materials see paragraph [0014]; and the potential loss of chemical properties in the deposited coating see paragraph [0014]. Despite the fact that pulsing was already well known in gaseous systems, my fellow inventors Goodwin et al and I did not think that it would be obvious or straightforward to adopt that technique in our own system, hence our failure to refer to pulsing in the document. Nor therefore did we provide any incentive for the reader to return to the art on gas-phase plasma deposition in order to improve upon our system.
- 6. I believe this is because the physical chemistry involved in a gas-phase plasma deposition process is very different to that which governs a process such as the one disclosed in Goodwin et al, where a liquid coating forming material is atomised into the exciting medium. So too are the mechanisms which act on the various fluids present, and which govern the excitation and eventual deposition of the coating materials. On this basis, the person of ordinary skill in the art

would not with confidence expect the advantages of pulsing in gaseous systems to transfer readily to systems involving atomised liquids.

- 7. The general principle behind the use of pulsing in gas-phase systems is that during the limited "on" period the plasma can excite the molecules of the coating forming material sufficiently to allow them to react with one another, but not enough to cause widespread fragmentation. During the "off" period the excited molecules react to form the intended coating. In this way, pulsing can help to maintain the structural integrity of the coating. It would not, however, have been clear to the skilled person whether or how those mechanisms would apply to atomised droplets of coating forming material. In a purely gaseous system, all molecules, ions and radicals are free to move around. In the atomised system this is not the case: there are constraints at the macromolecular (droplet) level, for example due to surface tension and molecular cohesion, and there are the effects of liquid evaporation to take into account. In a liquid-phase system, the substrate surface can become wetted by the atomised coating material; in the gas-phase process of Badyal et al, in contrast, there are no droplets present to spread across the substrate.
- 8. Moreover, in an atomised liquid system such as that shown in Goodwin et al, molecules can become trapped within the droplet structure, thus preventing them from behaving in the way that they would if present as a gas. Unexcited molecules (the precursors to the coating species) can become trapped within the droplets, and deposited into the coating layer before having the chance to react. The exciting medium begins to polymerise and cross-link the liquid droplets rapidly following atomisation, an effect which works from the outside of each droplet towards its centre. This tends to form a "skin" of reacted molecules: inside the skin, unreacted or partially reacted molecules remain trapped. Such complications do not arise in purely gaseous systems.
- 9. Any polymerisation process generates, in addition to the desired polymer, a distribution of oligomers of varying molecular weights. Lower molecular weight oligomers which become trapped in the droplets will compromise the structural integrity and hence the properties and performance of the coating. These species can also leach out during subsequent use of the coated product, causing toxicity issues.
- 10. The process of Goodwin et al is carried out at atmospheric pressure: the document is clear that this is an essential, and advantageous, feature of the process described. However this can exacerbate the entrapment problem. Under vacuum, lower molecular weight impurities can more readily be removed, but at atmospheric pressure they are more likely to remain

trapped both within the atomised droplets and subsequently in the deposited coating layer. When operating the process described in Goodwin et al, we generally noted a strong smell afterwards and subjected the coated products to vacuum treatment following deposition, to remove labile materials trapped inside the coatings (see Example 1 of Goodwin et al, and paragraph [0024]).

- 11. I believe that the person of ordinary skill in the art, having recognised the entrapment problem in the system of Goodwin et al, would have had no reason to believe that pulsing would solve it. Rather, he would have expected pulsing to increase the problem, in that the "off" periods, and the consequent lower average energy of the exciting medium, would increase the risk that molecules in the droplet centres would be unable to react in the desired manner. This too would have discouraged him from combining Goodwin et al with Badyal et al. His most obvious solution to the entrapment problem would probably have been to increase the overall power of the excitation field: he would have expected this to allow greater droplet penetration, and thus to avoid the formation of a reacted "skin" surrounding an unreacted centre. Yet increasing the power could also have been expected to reduce the structural integrity of the coating, due to increased fragmentation of the coating forming material.
- 12. Moreover, the entrapment problem which arises with the system of Goodwin et al is also well documented for systems where gaseous precursors are used in combination with pulsed plasmas at atmospheric pressure. See for example Annex II, which is a paper by Donohoe and Wydeven, ISPC 4 International Symposium in Plasma Chemistry No 4 (1979): 765-771. This paper describes atmospheric pressure pulsed discharge polymerisation of ethylene (see the abstract and introduction on page 765). In the third paragraph of the results section (page 766), the authors refer to an olefinic odour (similar to ethylene) in the polymerised films, showing that unreacted material had become trapped within the films during their formation. Since the combination of Goodwin et al with Badyal et al would also result in an atmospheric pressure, pulsed system, the skilled person would expect it to suffer from similar entrapment issues, exacerbated by the use of atomised droplets. He would therefore be further discouraged from attempting the combination.
- 13. Badyal et al does not address the entrapment problem because the problem does not occur when the coating precursors are free within a low pressure gas phase system rather than trapped within liquid droplets and constrained by atmospheric pressures. Thus, the skilled person would again be concerned that by combining Badyal et al with Goodwin et al, he would induce complications which are simply not foreseen, much less addressed, in Badyal et al. This

underlines the fundamental differences between a liquid-phase and a gas-phase system, and thus reinforces my belief that the person of ordinary skill in the art would have been discouraged from combining the systems of Goodwin et al and Badyal et al.

14. At the time that Goodwin et al was published, on April 11, 2002, it represented a departure from the widely known and well understood gas-phase technology. It was not, at that stage, so obvious that techniques used in gas-phase technology would work in the same way in the new atomised liquid system: rather, I believe that the skilled person would quite reasonably have expected complications had he tried to transfer the teachings from the known field across into the new one. It is telling that Goodwin et al itself says nothing about the application of a pulsed exciting medium to the atomised system it proposes.

15. Therefore, I conclude that the person of ordinary skill in the art would have been discouraged from combining the teachings of Goodwin et al and Badyal et al, at the priority date of the present application.

I further declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardise the validity of the application or any patent issued thereon.

Declarant's signature:

Jas Pal Singh BADYAL

Date

th June WII

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IN THE UNITED STATES PATEN	T AND TRADEMARK OFFICE
In re application of:	
Ward, Luke	Examiner: Burkhart, Elizabeth A
Application no: 10/516,448	Art unit: 1715
PCT filed: May 30, 2003	Confirmation no: 4683
Title: Application of a coating forming material onto at least one substrate	DECLARATION UNDER 37 C.F.R 1.132 (ANNEX I)

DECLARATION OF PROFESSOR JAS PAL SINGH BADYAL ANNEX I

This is Annex I referred to in my declaration.

Declarant's signature:

Jas Pal Singh BADYAL

Date

Heth Jones 20 4

CURRICULUM VITAE: JAS PAL BADYAL

1 DATE AND PLACE OF BIRTH

20th March 1964, Wolverhampton, England. Age = 46 years.

2 ACADEMIC QUALIFICATIONS

B.A./M.A.: in Natural Sciences, Cambridge University June 1985

Ph.D.: Surface Science Related to Hoterogeneous Catalysis: Structure, Unne 1988 Chemistry and Catalysis at the Ruthenium-Titania Interface,

with Professor Richard Lambert at the Department of Chemistry, Cambridge University

3 ACADEMIC EMPLOYMENT

Junior Research Fellow, King's College, Cambridge University
 Feb 1988 - Oct 1989

Oppenheimer Fellow, Cambridge University
 Oct 1988 - Oct 1989

Lecturer, Department of Chemistry, Durham University
 Oct 1989 - March 1996

Professor, Department of Chemistry, Durham University
 April 1996 – Present

4 ACADEMIC AWARDS / PRIZES

 1993 Harrison Prize for Most Meritorious and Promising Original Investigations in Physical/Theoretical Chemistry, the Royal Society of Chemistry
 March 1994

1995 Burch Prize for Outstanding Work in the Field of Surface Science,
 The British Vacuum Council (this is administered jointly by the Institute of Physics

and the Royal Society of Chemistry).

 \$15,000 DuPont Award in Recognition of Fundamental Studies Related to July 1997 Plasma Chemistry.

Winner of 1999 Procter & Gamble International UERP competition, \$100,000
 April 1999

EPSRC Advanced Research Fellowship for 5 years
 International Journal Editorial Board Membership

Journal of Adhesion Science and Technology Jan 1998 - Dec 2001

Plasmas and Polymers
 April 1999 – Jan 2005

Plasma Chemistry and Plasma Processing May 2005 -- present

ACS Applied Materials & Interfaces Jan 2011 - present

Oct 2000

6 INTERNATIONAL / NATIONAL COMMITTEE MEMBERSHIP

•	UK representative on the Plasma Science and Techniques Division of the International Union for Vacuum Science, Technique, and Applications (IUVSTA)	April 1998- March 2004
٠	Co-opted member of British Vacuum Council	April 1998- March 2004
•	International Bunsen Discussion Meeting: Conduction and Transport Mechanisms in Organic Materials: Preparation, Characterization and Applications Heidelberg, Germany (Joint meeting organized by the Deutsche Bunsen-Gesellschaft, Divisione di Chimien Pisica della Societa Chimica Italiana, Division de Chimien Pisica della Societa Chimica del Chimien, Faraday Division of the Royal Society of Chemistaty, and Fachvetbant) Chemische Physik de Deutschen Physikalischen Gesellschaft.)	27-30 Sept 1998
•	The Standing Committee on Conferences of the Faraday Division of the Royal Society of Chemistry	Sept 2000- Aug 2003
٠	International Scientific Committee for 14 th International Colloquium on Plasma Processes (CIP'2003), Antibes – Juan-les-Pins, France.	June 29 th - 3 rd July 2003
٠	Royal Society Industry Fellowships Scheme Joint Panel	1 Jan 2006 - 31 Dec 2008
•	UK representative on International steering committee of n-ABLE (Nanotechnology in Manufacturing)	1 st Nov 2005 -
٠	Chair and organizer of Zing Trends In Surface Chemistry International Conference, Antigua,	7 th -10 th Jan 2008
•	International Scientific Committee for The 3 rd International School of Advanced Plasma Technology, Villa Monastero, Varenna , Italy.	July 28-July 31, 2008

7 Invitations to Lecture at Overseas International Conferences	
 Plasma Versus Corona Activation of Polymer Surfaces (Invited Speaker) IBM International Symposium on Polymer Surface Modification, Las Vegas, USA. 	4 Nov 1993
 Plasma Polymerization of Organosilicon Precursors (Invited Speaker) IBM International Symposium on Plasma Polymerization/Deposition Las Vegas, USA. 	9 Nov 1993
 Structure, Chemistry, and Gas Berrier at the AlOy/PET Interface (Invited Speaker) 1st International Congress on Adhesion Science & Technology, Amsierdam, The Netherlands. 	16-20 Oct 1995
 Surface Fluorination Versus Oxidation of Polymer Surfaces (Invited Speaker) 1st International Congress on Adhesion Science & Technology, Amsterdam, The Netherlands. 	16-20 Oct 1995
XPS Characterization of Polymer Surfaces (Invited) Danish Society for Polymer Technology Copenhagen Denmark	31 Oct 1995
Structure, Chemistry, and Gas Barrier at the AlO _X -Polymer interface (Invited Speaker) Pharmaceutical and Medical Packaging '96, Copenhagen, Denmark.	7-8 May 1996
 Plasma Processing of Polymer Surfaces (Plenary Lecture) 5th International Conference on Plasma Surface Engineering Garmisch-Partenkirchen, Germany. 	9-13 Sept 1996
Characterization of Polymer Surfaces (Invited) Danish Society for Polymer Technology Copenhagen, Denmark	2 Oct 1996
Molecular Reaction Pathways During Plasma Modification of Polymer Surfaces (Invited Speaker) Americal Chemical Society Polymer Division Symposium: Plasmas and Polymers San Francisco, USA	13-17 April 1997
 Ultraselective Plasmachemical Reaction Pathways at Solid Surfaces (Invited Speaker) Materials Research Society Fall 98 Meeting Boston, USA. 	30 Nov - 1 Dec 1998
 Pulsed Plasma Surface Functionalization (Invited Speaker) Society of Vacuum Coaters 43rd Annual Technical Conference Denver, Colorado, USA 	15 th -20 th April 2000

 Controlled plasmachemical functionalization and adhesion of solid surfaces Poly Millennial 2000 Dec 9-13, 2000

Division of Polymer Chemistry of the American Chemical Society Macromolecular Plasma Chemistry Symposium Hilton Walkoloa Villages, Hawali 10-14th June 2001 · Controlled Plasmachemical Functionalization of solid surfaces (Opening Keynote Lecture) CIP'2001 (13th International Colloquium on Plasma Processes) Antibes, France · Plasma Deposition of Superhydrophobic Surfaces (Invited Speaker) Dec 3 - 7, 2001 7th Pacific Polymer Conference Division of Polymer Chemistry of the American Chemical Society Macromolecular Plasma Chemistry Symposium Oaxaca, México Surface Functionalization and Industrial Applications (Plenary Speaker) 18th-19th May 2005 International Symposium: Plasma Technologies for Industrial applications (Textile, Health, Food and Environment) Milan, Italy High Throughput Functional Nanocoatings (Invited Speaker) 26-28 Sept 2005 n-ABLE 2005, Nanotechnology in Manufacturing, Saarbrucken, Germany, High Throughput Functional Nanocoatings (Invited Speaker) 8th-10th Nov 2005 NanoSolutions 2005 EXPO XXI, Cologne International Expocentre, Germany High Throughput Functional Nanocoatings (Invited Speaker) 17th-18th Nov 2005 Technical Textiles Ghent, Belgium 'Re-Usable And Non-Leaching Antibacterial Nanocoatings' June 27 - 28, 2007 (Invited Speaker) Antimicrobials in Textiles and Plastics Applications IntertechPira, USA Prague, Czech Republic · Controlled Plasmachemical Functionalization of Solid Surfaces for April 28-30, 2008 Adhesion and Liquid Repellancy (Plenary Speaker) American Chemical Society 173rd International Rubber Division Technical Meeting, Dearborn, Michigan, USA Rewritable Bioarrays (Invited Speaker) 28-31July 2008 The 3rd International School of Advanced Plasma Technology, VIIIa Monastero, Varenna, Italy, 15th-19th Sept 2008 Bioactive Surfaces (Invited Speaker) E-MRS (European Materials Research Society) Warsaw, Poland 10th-12th March 2009 Functional Nanocoatings (Invited Speaker)

Smart Fabrics 2009 IntertechPira, USA Rome, Italy

Functional Nanocoatings (Invited Speaker)

International Conference on Plasma Processes and Applications

5-7 July 2010

Kirchberg, Luxembourg

•	Plasmachemical Tailoring of Solid Surfaces (Invited Speaker) 240th American Chemical Society (ACS) National Meeting Division of Colloid and Surface Chemistry Boston, USA	22-26 August 2010
•	Plasmachemical Functionalization of Polymer Surfaces for Adhesion and Liquid Repellency (Invited Speaker) 240th American Chemical Society (ACS) National Meeting Division of Colloid and Surface Chemistry Boston, USA	22-26 August 2010
•	Plasmachemical Deposition of Smart Functionalities (Invited Speaker) Food Packaging Innovations Graz, Austria	5-6 Oct 2010
•	Multi-Functional Nanocoetings (Plenary Speaker) 5th International Conference on Advanced Materials and Nanotechnology (AMN-5) Wellington, New Zealand	7-11 Feb 2011
•	Multi-Functional Nanocoatings (Invited Speaker) 8th International Conference on Polymer Surface Modification Danbury, Connecticut, USA	20-22 June 2011
•	Multi-Functional Nanocoalings (Invited Speaker) 5th International Conference on Developments in Materials, Processes and Applications of Emerging Technologies Alvor, Portugal	27-29 June 2011

8 LIST OF PUBLICATIONS AND PATENTS

8.1 REFEREED JOURNAL PAPERS

J P S Badyal is the principal author unless otherwise indicated by a [†] symbol. The 20 most significant papers are highlighted in bold.

- The origin of certain features in the Auger spectrum of Ru(0001): Impurilles, Auger transitions or diffraction effects?
 J.P.S., Badyal, A.J. Gellman and R.M. Lambert
 Surface Science 188 (1987) 557-562.
- *Single crystal modelling of the SMSI phenomenon: Structure, composition, electronic effects and CO chemisorption at the Ru(0001)/TiO₂ interface
 J.P.S. Badyal, A.J. Gellman, R.W. Judd and R.M. Lambert Catalysis Letters 1 (1988) 41-50.
- [†]Model studies of the SMSI phenomenon 1.CO end hydrogen chemistry at the Ru-Ti interface J.P.S. Badyal, A.J. Gellman and R.M. Lambert J. Catalvsis 111 (1988) 383-396.
- Model Studies of the SMSI Phenomenon at the TIO /Ru(0001) Interface
 J.P.S. Badyal, A.J. Gellman, R.W. Judd and R.M. Lambert
 Studies in Surface Science and Catalysis: Volume 48: Structure and Reactivity of Surfaces 1930 (1999, Elsevier, Amsterdam).
- †Chemistry and Catalysis at the Metal / Metal Oxide Interface J.P.S. Badyal, R.M. Nix and R.M. Lambert Faraday Discussions Chem. Soc. 87 (1989) 121-132.
- Modeculor Mechanism Of Heterogeneous Alkene Epoxidation: A Model Study with Styrene on Ag(111)
 S. Hawker, C. Mukold, J.P.S. Badyal and R.M. Lambert
 Surface Science 216 (1989) Le15-L622.
- 1) ¹The Mechanism of Alkene Epoxidation and Epoxide conversion on Single Crystal Silver Surfaces S. Hawker, C. Mukoid, J.P.S. Badyal and R.M. Lambert Studies in Surface Science and Catalysis: New Developments in Selective Oxidation (Elsevier, 1990) 739-746.
- Molecular Mechanism Of Alkene Epoxidation: A Model Study with 3,3-Dimethyl-1-Butene on Ag(111)
 C. Mukold, S. Hawker, J.P.S. Badyal and R.M. Lambert Catalvals: Letters 4 (1990) 57-82.
- [†]A Model Oxide Catalyst System for the Activation of Methane: Lithium-Doped NiO on Ni(111) J.P.S. Badyal, X. Zhang and R.M. Lambert Surface Science Letters 225 (1990) L154-19.
- 10) "X-ray Photoelectron Spectroscopic Characterization of Oxygen Surface Species on a Doubly Promoted Manganese Oxide Model Plenar Catalyst: Significance for CH₄ Coupling G.D. Moggridge, J.P.S. Badyal and R.M. Lambert. Journal of Physical Chemistry 94 (1990) 508-510.
- Novel Photoinduced Surface Oxidation of an Amorphous Samiconductor: An XPS Study of Vitrous Assemis Sulphide
 A.V. Kolobov, J.P.S. Badyal and R.M. Lambort
 Surface Science 222 (1999) ILB19-ILB24.

- [†]Electroactive Langmuin-Blodgett Films of O-Hoxadecytthiocarboxyletrathiafulvalene (HDTTTF)
 A.S. Dhindsa, J.P.S. Badyal, M.R. Bryce, M.C. Petty, A.J. Moore and Y.M. Lvov
 Chemical Communications 14 (1990) 970-972.
- [†]A Rapid Method for the Evaluation of Small Catalyst Samples G.D. Moggridge, J.P.S. Badyal and R.M. Lambert Journal of Vacuum Science and Technology A8 (1990) 3874-3875.
- Surface Oxide Films and H₂/CO Chemisorption at the Ru/TiO₂ Interface: Studies with a Model Filaner Catalyst
 J.P.S. Bardyal and R.M. Lambert
 J. Callabisi 190 (1991) 173-180.
- Investigation of the SMSI Phenomenon with TiO₂/Ru/SiO₂ Model-Dispersed Catalysts J.P.S. Badyal, R.M. Lambert, K. Harrison, C. Riley and J. Frost J. Catalysts 129 (1991) 486-496.
- V-Rey Induced Fluoropolymeric Encapsulation of TiO₂ Particles: An XPS Investigation J.P.S. Badyal, Z. Chvatal, R.D. Chambers and R. Templeton-Knight J. Chem. Soc. Faraday Transactions 87 (1991) 991-993.
- The Variation in Chemical Character of Plasme Polymerized Perfluorohexane A.G. Shard, H.S. Munro and J.P.S. Badyal Polymer Communications 32 (1991) 152-154.
- 19 Imvastigation of the Strong Metal Support Interaction State of Ru/TiO₂ by H Nuclear Magnetic Resonance.
 P. Jonsen, C.C.A. Riley, P. Meehan, J.C. Frost, K.J. Packer and J.P.S. Badyal Catalvalis Today 9 (1991) 121-127.
- [†]Highly-Conducting Langmuir-Blodgett Films Based on Ni(dmit)₂ Anions A.S. Dhindsa, J.P.S. Badyal, C. Pearson, M.R. Bryce and M.C. Petty. Chemical Communications 5 (1991) 322-323.
- Plasma Versus UV Enhanced Oxidation of Polyethylene A.G. Shard and J.P.S. Badyal Polymer Communications 32 (1991) 217-219.
- [†]An Electrical Investigation into Multilayer Assemblies of Charge-Transfer Materials J.J. Alekna, M. Petty, M.C. Petty, A.S. Dhindsa, J.P.S. Badyal and M.R. Bryce Journal of Physics D: Applied Physics 24 (1991) 1422-1429.
- Toxygen Surface Species on Lithium Nickelate Methane Coupling Catalysts and Their Interaction with Carbon Cixides
 G.D. Moggridge, J.P.S. Badyal and R.M. Lambert
 J. Catalysis 132 (1981) 92-99.
- Plasma Oxidation Versus Photooxidation of Polystyrene A.G. Shard and J.P.S. Badyal J. Physical Chemistry 95 (1991) 9436-9438.
- Surface Modification of PVDF by LiOH
 R. Crowe and J.P.S. Badyal
 Chemical Communications 14 (1991) 958-959.
- Plasma Oxidation of Copper-Silver Alloy Surfaces J.M. Knight, R.K. Wells and J.P.S. Badyal Chemistry of Materials 4 (1992) 640-641.

- 28) Pissma Enhanced Chemical Vapour Deposition of Bulk Organositicon Solids Using Hexamethydideline Precursor J.L.C. Fonseca, D.C. Apperley and J.P.S. Badyal Chemistry of Materials (1992) 1271-1275.
- Surface Oxidation of Polyethylene, Polystyrene and PEEK: The Synthon Approach A.G. Shard and J.P.S. Badya.
 Macromolecules 25 (1992) 2053-2054.
- 28) Photooxidation of Polystyrene by O₂ and N₂O R.K. Wells and J.P.S. Badyal J. Polymer Science, Polymer Chemistry Edn. 30 (1992) 2677-2681.
- Plasma Polymerization of Hexamethyldisilane onto Polyethylene Film J.L.C. Fonseca and J.P.S. Badyal Macromolecules 25 (1992) 4730-4733
- [†]Polyfluoroalkyl derivatives of polyethers J.P.S. Badyal, R.D. Chambers and A. Joel J. Fluorine Chemistry 58 (1992) 334.
- [†]Electronic, Structural and Spectroscopic Properties of Langmuir-Blodgett Films of Heixadecylthicocarboxylotrathlativalene (HDTTTF)
 A.S. Dhindsa, Y.-P. Song, J.P.S. Badyal, M.R. Bryce, Y.M. Lvov, M.C. Petty and J. Yarwood Chemistry of Materials 4 (1992) 724-728.
- [†]Gemma-Rey Induced Encepsulation of Titanium Dioxide using Fluorinated Alkenes J.P.S. Badyal, R.D. Chembers, Z. Chyatal and G. Descelles Journal of Fluorine Chemistry 57 (1992) 159–167.
- Novel Surface Segregation Phenomena at the Plasma/Copper-Sliver Alloy Interface J.M. Knight, J.L.C. Fonseca, Z.V. Hauptman and J.P.S. Badyal Chemistry of Materials 5 (1993) 1221–1226.
- 34) Plasma-Catalyzed Surface Rearrangement of Poly(ethylene) to a Poly(propylene) Type Structure R.K. Wells, I.W. Drummond, K.S. Robinson, F.J. Street and J.P.S. Badyal Chemical Communications 6 (1983) 549-550.
- Photochemistry at the Organosilane / Polymer Interface R.K. Wells and J.P.S. Badyal Macromolecules 26 (1993) 3187-3189.
- Plasma Polymerization of Tetramethylsllane
 J.L.C. Fonseca, D.C. Apperley and J.P.S. Badyal
 Chemistry of Materials 5 (1993) 1676-1682.
- Modelling of Non-Isothermal Glow Discharge Modification of PTFE Using Low-Energy Ion Beams R.K. Wells, M.E.Ryan and J.P.S. Badyal Journal of Physical Chemistry 97 (1993) (2879-12881.
- A Comparison of Plasma-Oxidized and Photo-Oxidized Polystyrene Surfaces R.K. Wells, I.W. Drummond, K.S. Robinson, F.J. Street and J.P.S. Badyel Polymer 34 (1993) 3611-3613.
- 39) Strong Metal-Support Interactions (Invited Review) J.P.S. Badyal Chapter 10, In The Chemistry of Solid Surfaces and Heterogeneous Catalysis, Volume 6,

Elsevier, (1993) 311-340.

- Partly Fluorinated Polyethers as Additives for Surface Modification J.P.S. Badyal, R.D. Chambers and A.K. Joel J. Fluorine Chemistry 60 (1993) 297-300.
- Catalysis in Ultra-High Vecuum: Oxidative Dehydrogenation of Cycloalkenes on Ag(111) S. Hawker, C. Mukold, J.Ps. Badyal and R.M. Lambert Vacuum 45 (1993) 275-278.
- Direct Evidence for the Generation of Phenyl Radicals and Cross-Linking During the Photolysis of Polystynee Film R.K. Wells, A. Royston and J.P.S. Badyal Macromolecules 27 (1994) 7465-7468.
- Surface Defluorination of PTFE by Sodium Atoms
 Tasker, R.D. Chambers and J.P.S. Badyal
 Journal of Physical Chemistry 98 (1994) 12442-12446.
- Piasma Modification of Poly(ether sulfone)
 J. Hopkins and J.P.S. Badyal
 Macromolecules 27 (1994) 5498-5503.
- Influence of Cross-Linking upon the Mecroscopic Pore Structure of Cellulose S. Tasker and J.P.S. Badyal
 Journal of Physical Chemistry 98 (1994) 7599-7601.
- A Comparative Study of the Silent Discherge Treatment of Saturated and Unsaturated Hydrocarbon Polymers
 D. D. Greenwood, S. Tasker and J.P.S. Badyal
 J. Polymer Science, Polymer Chemistry Edn. 32 (1994) 2479-2486.
- Hydroxyl Accessibility in Celluloses
 S. Tasker, S.C.E. Backson, R.W. Richards and J.P.S. Badyal Polymer 35 (1994) 4717-4721.
- Plasma-Enhanced Chemical Vapour Deposition of TIO_Polymer Composite Layers
 P.J. Ratcliffe, J. Hopkins, A.D. Filzpatrick, C.P. Barker and J.P.S. Badyal
 Journal of Materials Chemistry 4 (1994) 1055-1069.
- 49) Plasma Oxidation of Polystyrene Versus Polyethylene R.K. Wells, I.W. Drummond, K.S. Robinson, F.J. Street and J.P.S. Badyal Journal of Adheston Science and Technology 7 (1993) 1129-1137. Plasma Surface Modification of Polymers: Relevance to Adhesion, Editors M. Strobel, C.S. Lyors, and K.L. Mittal, 1994, VSP, ISBN 90-0764-1642.
- 50) [†]The Surface Modification of Polyethylene by Solution-Phase Photochemical Grafting Using Short Irradiation Times L.M. Hamilton, A. Green, S. Edge, J.P.S. Badyal, W.J. Feast and W.F. Pacynko. Journal of Applied Polymer Science 52 (1994) 413-419.
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Atty docket no: 52309-P004US Client ref: ARB/P1846US00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Ward, Luke

Application no: 10/516,448

PCT filed: May 30, 2003

Title: Application of a coating forming material onto at least one substrate

Examiner: Burkhart, Elizabeth A

Art unit: 1715

Confirmation no: 4683

DECLARATION UNDER 37 C.F.R. 1.132 (ANNEX II)

DECLARATION OF PROFESSOR JAS PAL SINGH BADYAL ANNEX II

This is Annex II referred to in my declaration.

Declarant's signature:

Jas Pal Singh BADYAL

14th January 2011

Date

PLASMA POLYMERIZATION OF ETHYLENE IN AN ATMOSPHERIC PRESSURE DISCHARGE

Kevin G. Donohoc and Theodore Wydeven Ames Research Center, NASA, Hoffett Field, California 94035

Keywords: Plasma polymerization, Brownian motion

Compounds: Belium, Ethylene, Acetylens, Ethane

ABSTRACT

1. INTRODUCTION

At resent, nost reported plasma processes are carried out at low presures, usually 300 km² or isse. We describe hors a plasma polymentation of the complete present (010 km²) when the complete present (010 km²) interest in operating case that it is the complete present (010 km²) interest in operating case that it is account adventages. Also, it was maticipated that operation at high partial presence of noncear sight result in high film deposition rate. Bylgene moment was chosen become its polymerisation has been studied in datall in low presents discharges, (1.1)

2. EXPERIMENTAL

As Advances and Delegation of the Circuit and reactor are shown in Fig. 1. The circuit condition of a high voltage 60-Hz power supply which charges the cuit condition of a high voltage 60-Hz power supply which charges the period power for the condition of the c

Breakdown wwwsforms are shown in Fig. 2. Since the circuit and the electrodes are symmetric, the breakdown waveforms do not depend on the initial polarity. The breakdown waveforms thow two characteristics: a breakdown that the circuit begins to lead down due to current I can be the circuit begins to lead down due to current I can be the circuit begins to lead down due to current I can be the circuit begins at Which current stops Electing. The current is a pulse which begins at Va, renches a mexicam, and dropt to zero at Va, it flows

for about 100 me. So, at a spark gap firing rate of 480/sec, a discharge occurs 480 times per accord.

The reactor (Fig. 3) constant of a plans pipe cross with a 15.2 cm. 4.4, to the direction of pass flow and a 10.6 cm. 4.4 clong the electrode axis. The electrodes, which were brane diaks 9.5 cm in disaster and 1.25 cm thick with edges of 0.16-cm reactify, were potent in polypester casting reading the control of the cont

3. RESULTS

Speciation of a uniform slow discharge in pure elliptions was not possible on stronghetic pressures. A discharge in pure altypica constricted at pressures showed & bildra. Bitch halium as a dissect, a uniform discharge could be maintended at a portial pressure of adoptions of 8 bildra. This increase the pressure of the pressure of the pure of the pressure of the p

Pline were deposited on glass microscope slides oriented parallel to the electrode faces. Deposition rates were independent of vertical position and were the same on the lower and upper nurfeces of the glass slides. Online the control of the cont

In all cases, the plesma polymerized ethylene films were uncolored, solubla in ethenol, and had an olefinic odor (similar to ethylene) which diaappeared after a few weeks of storage in room air.

Infrared transmission spectra of films deposited on cesium iodide windows showed no absorption around 1600 cm⁻¹, indicating the absence of significant amounts of vinyl, groups or unsaturation in the polymer films.

Measured analysis of a cycled fills yielded the collecting amplified forusuals (501-1,001-1, Dyrical Hearters winners) are the collection forusuals (501-1,001-1, Dyrical Hearters winners) are the collection of the collection observed here is a 5.55 suggeste that less unsaturation or present that of the present that of the collection observed here is a sanopheric present that or the present that of the present that or the present t

An important difference between polymerization in this atmospheric presure pulsed discharge and in low pressure if discharges is that in the high pressure discharge, oligometa lerge enough to wishly acater light from a Raw-R laser (52.1 m) were clawys observed at the gas phase. The pressure of the control of the control of the control of the control cultural control of the control of the control of the control of the political value, their gas phase density (antimated visually under laser light illustration) was highest under conditions of highest rates of depovers not clear; they were fogged and almost opense. It has been noted that in low preserved discharges, high deposition rates are also eccompated by powder forestion and the production of posser (fins. 10 Pogita) of films can be caused by surface roughness or by the presence of scattering conters embedded in the bulk film. A prior scanning electron microrelation films of the prior scanning electron micromicro films of the prior scanning of the prior scanning of the scanning

The aspirates of the surface roughness required to cause fagging on he extinated. Diffuse relicatone spline when the roughness beight he is greater than 1/16 for normal incidence of light of surveying his consequent of the correspond to he hatness 23 and of the mean of the correspond to he hatness 23 and of the mean of the complex of the correspond to the complex of the complex

Effect of Spark Gap Firing Rate. The power in a pulsed discharge can be varied aither by the power per pulse or by the pulse repetition rate. With the circuit used here, the power per pulse can be veried by the magnetist of the power per pulse can be veried by the magnetist of the power per pulse can be veried by the superior of the power per pulse can be veried by the power discover the veried by the power per pulse power that the first per the first of the Go-840/sec), the average power veried directly with the firing rate. This power was 0.5 W at z ret of 480/sec with e peak pulse power of 15 kM.

The affect of verying the interpretation in Fig. 4. The fifth depodiction rote verying the interpretation in Fig. 4. The fifth deposisted new verying the interpretation of the property of the control suggesting that constant amount of polymer is formed such control charge occurred. Per reter greater them 600/sec, the deposition carried increased monitoredly, indirecting that now charge in the mechanism(s) of deposition occurred, or that a nonlinear relationship between the producdoposition occurred, or that a nonlinear relationship between the production of the continues of the control of the continues and deposition rate.

The othylese concentration was also measured. A smapling probe and garanteen chromatograph were used to escaping estimate state the discherge, ENGMEN concentrations were constant in the direction perallel to the electric field and decreased nearly linearly in the Hose direction. Therefore, itself and discherge estimates and the state of the

Nifred of the Fibro habe. Figure 5 shows the file deposition race we then we are followed for the fade concentrations. The range of lines were response to man rendement these from 60 set to 1300 set (the fibro vates are 1877). The characteristic time for diffusion of exhylens across the set 1877), the characteristic time for diffusion of exhylens consume the for which diffusion was fast compared to the constant of the characteristic constant to the characteristic constant and the characteristic characteris

Gaseous Dischurge Products. Gas chromatographic analyses of the gas in the discharge showed that early-leas was the select volutile product. Ethnes was also produced but in a much lower concentration than acceptance. 10.07 crages. No other gaseous products were observed (utdust had detection limits of the chromatograph). These results are shaller to those obtained pressurer of descharge in exhiption, mankysis of the efficient force is not

4. DISCUSSION

The nest obvious difference between files that were produced under difference. The nest obvious difference seems of the nest obvious difference or agreement of the nest obvious diffe

The following discussion includes a description of the motion of these oligowers in the gas phase and a description of the proposed gas phase chemical reactions.

Chemical Reactions in the Gam Fhase. Chromatographic analysis of the gas in the discharge showed that the rate of disappearance of athylane did not vary directly with the fill deposition rate. It also revealed that acetylane was the principal gaseous product of tha ethylane-helium discharge and only traces of tighar molecular weight hydrocarbons were present. The appearance of acetylane is consistent with a free radical mechanism for polymerization similar to the one proposed (*) to describe the low pressure polymerization of ethylese in sm rf discharge. In this mechanism, indication is by electron impact on GyBa, propagation is by radical addition to GyBa, and eventuation occurs by the reaction between two radicals.

Oligomes Motion in the Gas Phase. The observation that the fill deposition rate was energy independent of feed consentration, for wate, and extent of athylens castion over wide ranges of these variable are supported that some mean transfer process indicate the elegosition rate. Therefore, an attempt was made to relate the motion of the oligomers in the gas phase to the observed deposition rates.

The motion of microsetr- and submicroseter-stase particles in the parameter of the convection formula motion, and sessionnession. Convection occurred perpendicular to the direction of the mass flux that proved the control of the co

It is of interest to note that listed aggloweration of the oligoners would have a relatively small effect on the Brownian motion of the agglowerates because the Brownian diffusion coefficient varies with the reciprocal of the particular radius, For engage, a cotofi increase in the particular state, For engage, a cotofi increase in the particular could have to combine to decrease the Brownian diffusion rate by a factor of 2. This raticality insensitive response for the diffusion coefficient to agaloweration is a likely explanation for the fact ratio is independent of gas likely response to the affine state of the contract is independent of gas flow rate over such a large range of Lipsy rates was such a large

5. SUMMARY AND CONCLUSIONS

Dames paymerization of trylens has been consisted in a prised electrical declarity discharge decidency decidency electroners. Then produced as this discharge were soft, uncolored, soluble in athend, and passed the cell-phane tape pull test for athendon to a glass substrata. These observations, coupled with the infrared spectra and classmanl analysis of the polymer, indicated that the degree of unscaturation analyser consistentiating was represented by the constant of the co

A free reficie. Other resection estemes[9] to explain the polymerization is consistent with the results estated in this work. Gas chrosmographic analysis of the gas in the planes revealed that costylene was the principle analysis of the gas revealed that costylene was the principle analysis of the gas and the principle and the principle analysis of the gas in the planes revealed that costylene was the principle analysis of the principle and the cliptoner formed in the gas planes is suggested to be the race-inlating step in the fills deposition process under the conditions of constant fitting rates and low duty cycle.

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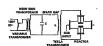


Fig. 1. Schenatic of the discharge circuit and reactor,



Fig. 2. Oscillogram of the breakdown voltage waveforms.

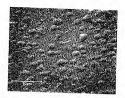


Fig. 3. SEN photograph of a fogged film with the sample at an angle of 45° relative to the electron beam.



Fig. 4. Film deposition rate (O) and extent of ethylene reaction (C) vs. spark gap firing rate.

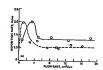


Fig. 5. Film deposition rate vs. gas flow rate (NPT). O - 1% C₂H₄ in feed, U - 2% C₂H₄ in feed. Firing rate: 480 s⁻¹,